



L Number	Hits	Search Text	DB	Time stamp
1	376	438/30.ccls.	USPAT	2002/12/11 18:00
2	1		USPAT	2002/12/11 17:40
3	1		USPAT	2002/12/11 17:40
4	50	438/30.ccls. and photoresist and mask and	USPAT	2002/12/11 18:16
1		passivation	001111	2002,12,11 10.10
5	0	438/30.ccls. and photoresist and mask and	USPAT	2002/12/11 18:01
	Ū	passivation and semi-transmissive	ODIAI	2002/12/11 10:01
1 ~	24249	438/30.ccls. and photoresist and mask and	USPAT	2002/12/11 18:02
6	24249		USPAT	2002/12/11 18:02
_		passivation and semi transmissive		0000/10/11 10 00
7	1	438/30.ccls. and photoresist and mask and	USPAT	2002/12/11 18:02
		passivation and semi and transmissive		
8	50	438/30.ccls. and photoresist and mask and	USPAT	2002/12/11 18:12
1		passivation		•
9	34	438/30.ccls. and (samsung.as. or lg.as.)	USPAT	2002/12/11 18:04
10	1		USPAT	2002/12/11 18:05
11	1		USPAT	2002/12/11 18:05
12	1		USPAT	2002/12/11 18:05
13	283	438/30.ccls. and mask	USPAT	2002/12/11 18:23
14	66821	349/\$.ccls. or 438/30.ccls. or 430/\$.ccls.	USPAT	2002/12/11 18:23
15	51	schechter.xa.	USPAT	2002/12/11 18:26
16	35	349/\$.ccls. and chung.xa.	USPAT	2002/12/11 18:42
1	386	349/113.ccls.	USPAT	2002/12/11 18:52
17	*	349/113.0018.	USPAT	
18	1		1	2002/12/11 18:44
19	1		USPAT	2002/12/11 18:44
20	33	349/113.ccls. and exposure and	USPAT	2002/12/11 19:02
		photolithography and mask		
23	2348	430/5.ccls.	USPAT	2002/12/11 19:02
22	277	430/20.ccls.	USPAT	2002/12/11 19:04
24	2	430/20.ccls. and photoresist and	USPAT	2002/12/11 19:04
		passivation and mask and exposure		
25	18	430/5.ccls. and photoresist and	USPAT	2002/12/11 19:15
		passivation and mask and exposure		
26	1		USPAT	2002/12/11 19:05
27	1		USPAT	2002/12/11 19:05
28	1		USPAT	2002/12/11 19:05
29	1		USPAT	2002/12/11 19:11
30	1		USPAT	2002/12/11 19:11
31	1		USPAT	2002/12/11 19:11
32	1		USPAT	2002/12/11 19:15
		1430/30 cala and comi transport		1
33	2	1	USPAT	2002/12/11 19:16
34	558	430/\$.ccls. and semi-transparent	USPAT	2002/12/11 19:16
35	0	430/\$.ccls. and semi-transparent and mask	USPAT	2002/12/11 19:17
		and exposure and photolithography and		İ
		passivation and photoresist		
36	106		USPAT	2002/12/11 19:19
		photolithography and passivation and		
		photoresist		
37	1	<mark>"</mark> 6391499"	USPAT	2002/12/11 19:19
38	12	"4415262"	USPAT	2002/12/11 19:20